

Appl. No.: 10/087,146  
Amdt. Dated: December 16, 2003  
Reply to Office Action of: October 10, 2003

**Amendments to the Specification:**

Please replace the originally filed abstract with the following amended abstract:

**Abstract of the Invention**

The invention provides a method of making  $\geq 4$  kHz repetition rate argon fluoride excimer laser crystal optics. The method includes providing a solid magnesium fluoride crystal solid precursor, nonmetallically crushing the ~~magnesium~~ fluoride solid precursor to provide a crushed, low metal contaminant ~~magnesium~~ fluoride feedstock, providing a ~~magnesium~~ fluoride crystal growth crucible, loading the crushed ~~magnesium~~ fluoride feedstock into the crystal growth crucible, melting the loaded, crushed ~~magnesium~~ fluoride feedstock to provide a precrystalline ~~magnesium~~ fluoride melt, growing an oriented magnesium fluoride crystal from the precrystalline ~~magnesium~~ fluoride melt, cooling the grown ~~magnesium~~ fluoride crystal to provide a magnesium fluoride laser optical crystal having a 120 nm transmission of at least 30%, and forming the ~~magnesium~~ fluoride laser crystal into an excimer laser crystal optic for transmitting a high repetition rate ( $\geq 4$  kHz repetition rate) excimer laser output.